



AUTOMATED CHEMICAL SOLUTIONS

Chemicals and Controllers for PWB Fabrication

Product Overview

AUTOstrip RS-5530

Photoresist Stripper

Product Description

AUTOstrip RS-5530 is a photoresist stripper concentrate formulated specifically for use with today's multipurpose and plating photoresists. AUTOstrip RS-5530 is formulated to break the resist into very small piece sizes to aid in removal from fine and/or overplated features without the use of glycol ethers. AUTOstrip RS-5530 strips quickly at very low concentrations and leaves the copper surface clean and free of oxidation. AUTOstrip RS-5530 is designed to completely remove the tenacious adhesion promoters used in many of today's photoresists.

Physical Properties

Specific gravity:	1.0
pH:	> 13
Appearance:	clear, light amber liquid
Flash point:	> 200 °F

Operating Parameters

Concentration:	4 - 8% v/v
Temperature:	120 – 160 °F

Safety

CAUTION! RS-5530 concentrates and working solutions contain strong alkaline ingredients. Avoid contact with eyes, skin and clothing. Wear chemical handler's gloves, goggles and protective clothing when handling. Read and understand Material Safety Data Sheet before using this product.

Notice

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